MB86R12 Application Note DDR3 Interface PCB Design Guideline

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Preface

This guideline describes PCB design restrictions related to MB86R12 DDR3 interface signal wiring.

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Revision History

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1. Floor plan

Figure 1-1 shows the reference example of the floor plan of MB86R12 and connected DDR3 SDRAM devices.

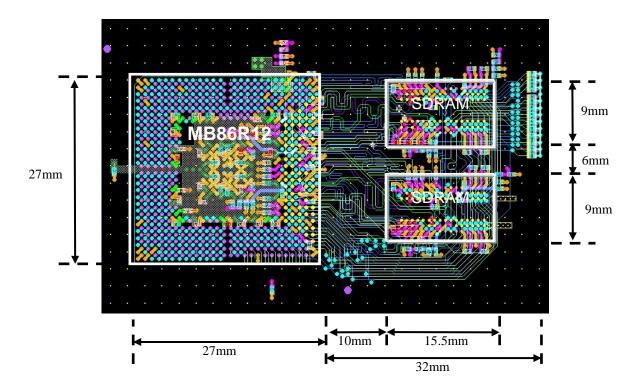


Figure 1-1 Reference example of the floor plan of MB86R12 and DDR3 SDRAM devices

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2. PCB laminating

This chapter shows the recommended laminating conditions of the PCB.

Figure 2-1 PCB laminating

Specified condition of wiring layer

- L1 and L8 are used as wiring and pull-out wiring layer of CLK.
- L3 and L6 are used as wiring layer of DQS, DQ, and CMD/ADD.
- L2 and L5 are used as power layer.
- L4 and L7 are used as GND layer.

3. DDR3_SDRAM specifications

This chapter shows DDR3_SDRAM that can be used for the DDR3 interface with MB86R12. If an alternative device fulfills the same requirements, it can also used.

Please note however, that if you use an alternative device, there may be differences concerning I/O quality which may require your attention. However, all I/O characteristics should be checked as could differ. Even if you use the device(s) listed below, you must refer to the specifications provided by the DRAM manufacturer for the confirmation of details (e.g. operating temperature conditions etc.).

Table 3-1 Recommended DDR3_SDRAM

Manufacturer	Product name	IBIS model name	Driver strength	Remarks
Micron	MT41J128M16HA-15E	v69a_at.ibs		It has already been verified by
Technology, Inc.	(2Gb 1333Mbps)			the transmission line analysis.

4. Signal design restrictions (DDR3 interface part)

This chapter describes the signal wiring design restrictions for the DDR3 interface part.

4.1. Definition of signal line group

In order to make the requirements for wiring configurations described further on in this document easier to understand, the DDR3 interface signals are classified into the groups listed below.

Wiring preferential order	Group name	Pin name of MB86R12
1	MCK_Group	MCK, MXCK
2	MDQS0_Group	MDQS0, MXDQS0
	MDQS1_Group	MDQS1, MXDQS1
	MDQS2_Group	MDQS2, MXDQS2
	MDQS3_Group	MDQS3, MXDQS3
3	MDQ0_Group	MDQ0~MDQ7, MDM0
	MDQ1_Group	MDQ8~MDQ15, MDM1
	MDQ2_Group	MDQ16~MDQ23, MDM2
	MDQ3_Group	MDQ24~MDQ31, MDM3
4	MCNTL_Group	MCKE, MXCS, MODT
5	MCMD_Group	MA0~MA14, MBA0~MBA2, MXCAS, MXRAS, MXWE

Table 4-1 DDR3 interface signal grouping

4.2. General wiring restrictions

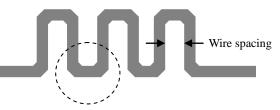
This section describes the general wiring restrictions.

- It is recommended that signal wiring be designed to have the following characteristic impedance. Single impedance: $50\Omega \pm 10\%$
 - Differential impedance: $100\Omega \pm 10\%$
- Signal wiring on power layer and GND layer should be sufficient width to guarantee the flow of return current. (Signal line should be wired on the same power group or GND group. It must not cross over other power and GND groups.)
- Please use parallel wiring for the positive and negative signals of the differential MCK_Group and MDQSx_Group signals. In addition, also take care that the position and number of layer vias is the same.
- The following groups must wire the same layer respectively, and the number of layer transfer vias must become the same, too.

MDQS0_Group and MDQ0_Group MDQS1_Group and MDQ1_Group MDQS2_Group and MDQ2_Group MDQS3_Group and MDQ3_Group

There are no restrictions to the number of layer transfer vias for other signals, but use a minimum possible.

• When using meander wiring layouts for signal delay, crosstalk may occur and the delay value reduced, therefore having wider spacing between wirings is recommended. The recommended wire spacing is about five times the wiring width.



Bevelled corners used in order to reduce signal reflections

Figure 4-1 Meander wiring

The recommended conditions and the simulation waveform which are described further on in this document are valid under the above conditions.

If your design greatly differs from the above conditions, then please run a simulation on your wiring.

4.3. Resistance

- Resistors described in this guideline should be generally selected from the E12 series. E12 series: 10, 12, 15, 18, 22, 27, 33, 39, 47, 56, 68, 82
- The following resistance tolerance values should be used (according to the resistance type): Terminal resistance: under ±5% Divider resistance for VREF: under ±1%

4.4. Terminal resistance/Damping resistance/Wire length

Table 4-2 shows the recommended resistance value and wire length for each group. The wiring topology diagram relevant to this section is shown in "4.7. Wiring topology".

No.	Group name	External terminal resistance value (Rt)	Damping resistance value (Rd)	Wire length from MB86R12 output to SDRAM input	Internal group approved wire length variation
1	MCK_Group	$39\Omega \times 2$ 0.1µF capacitor × 1 (Refer to "4.7.1.")	N/A	Refer to "4.7.1."	Meet the conditions of "4.7.1."
2	MDQSx_Group	N/A	N/A	Refer to "4.7.2."	Meet the conditions of "4.7.2."
3	MDQx_Group	N/A	N/A	Refer to "4.7.3."	Meet the conditions of "4.7.3."
4	MCNTL_Group	39Ω	N/A	Refer to "4.7.4."	Meet the conditions of "4.7.4."
5	MCMD_Group	39Ω	N/A	Refer to "4.7.4."	Meet the conditions of "4.7.4."

 Table 4-2
 Resistance value and wire length list

4.5. Wiring gap/Crosstalk

Please keep to the wiring configurations shown below in order to avoid malfunctions and deteriorated signal integrity due to crosstalk.

(1) The recommended gap for wiring within MDQx_Group and MCMD_Group groups should be over $300\mu m$.



Figure 4-2 Gap for wiring within MDQx_Group and MCMD_Group

(2) The gap for wiring with other groups should be over $300\mu m$.



Figure 4-3 Gap for wiring of other signal groups

(3) Differential wiring signals of MCK_Group and MDQSx_Group should use a wiring gap of over 500µm to other signals.

If it is difficult to guarantee a gap above $500\mu m$, separate the wire from other signals using a GND area. However, please take the consequent decrease of the wiring impedance into consideration.

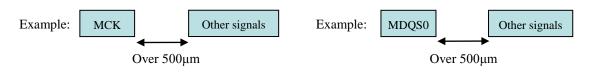


Figure 4-4 Gap for wiring between signal in MCK_Group/MDQSx_Group and other signals

4.6. ZQ/ODT setting

Table 4-3 shows the ZQ setting conditions.

Table 4-3ZQ setting conditions

Group name	Output impedance of MB86R12 I/O (RON)	ZQ setting of MB86R12
MCK_Group	40Ω	
MDQSx_Group	48Ω	
MDQx_Group	48()	Perform the ZQ calibration, and set it automatically.
MCNTL_Group	60Ω	
MCMD_Group	60Ω	

Table 4-4 shows the recommended ODT setting conditions for MDQSx_Group and MDQx_Group signals.

Table 4-4ODT setting conditions

Operating condition	MB86R12	DDR3_SDRAM
Write to DDR3_SDRAM	Off	60Ω
Read from DDR3_SDRAM	40Ω	Off

4.7. Wiring topology

This section illustrates the recommended wiring topology of each group.

4.7.1. Wiring topology diagram of MCK_Group

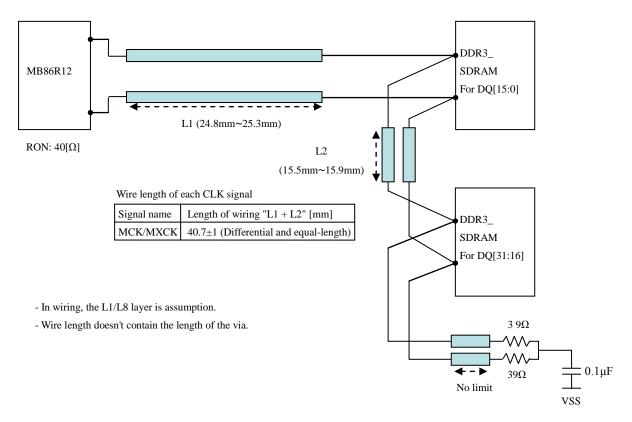
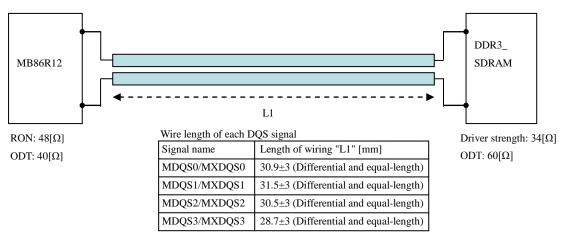


Figure 4-5 Wiring topology diagram of MCK_Group

4.7.2. Wiring topology diagram of MDQSx_Group

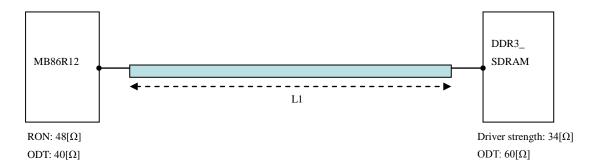


- In wiring, the L3/L6 layer is assumption.

- Wire length doesn't contain the length of the via.

Figure 4-6 Wiring topology diagram of MDQSx_Group

4.7.3. Wiring topology diagram of MDQx_Group



- In wiring, the L3/L6 layer is assumption.

- Wire length doesn't contain the length of the via.

5.1±2 2.0±2 0.9±2 4.5±2 2.7±2
2.0±2 0.9±2 4.5±2
2.0±2 0.9±2 4.5±2
0.9±2 4.5±2
4.5±2
2.7+2
4.1±2
4.8±2
3.3±2
2.5±2
4.7±2
3.2±2
1.3±2
5.9±2
3.4±2
6.6±2
3.9±2
5.0±2
6.4±2

Wire length of each DQ signal

Note 1) The DQ signal can be shuffled in byte.

Figure 4-7 Wiring topology diagram of MDQx_Group

4.7.4. Wiring topology diagram of MCNTL_Group/MCMD_Group

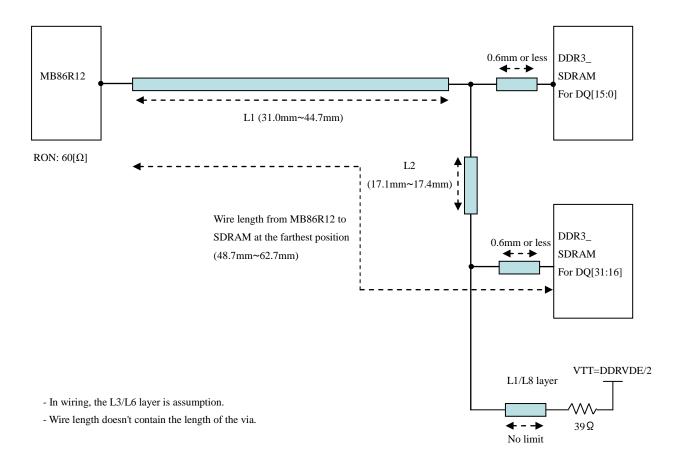


Figure 4-8 Wiring topology diagram of MCNTL_Group/MCMD_Group

5. Power system design restrictions

This chapter describes the power system design restrictions for the DDR3 interface part of MB86R12.

5.1. Number and capacity of bypass capacitor

Table 5-1 shows recommended number of bypass capacitors for the high frequency noise removal for which mounting is necessary directly under MB86R12.

Pin name of MB86R12	Power supply voltage	Recommended number of bypass capacitors 0.1µF	Remarks
DDRVDE	1.5V	18	For DDR3 interface
VSS	0V	-	

 Table 5-1
 Recommended number of bypass capacitors

- If capacity is a value close to 0.1μ F (0.22μ F etc. for instance), the bypass capacitor can be used.
- Place the 0.1μ F capacitor as close as possible to the power/GND pins of MB86R12 (refer to "5.2. Pull-out wiring condition").
- For the 0.1 μ F capacitor, we recommend the use of ceramic capacitors of under size 1005 (1.0mm \times 0.5mm).

In addition, use low ESL (Equivalent Series Inductance) value components where possible in order to decrease noise.

- Mount a high-capacity capacitor for the low frequency if needed. One 100μ F is recommended to be used for the current variation of 1A only as a guide.
- Verify your board design by simulations and measurements if you can not mount capacitors of the above number.

5.2. Pull-out wiring condition

This section shows the example of mounting the bypass capacitor for the high frequency noise removal. Be sure to meet the following pull-out wiring conditions to reduce the inductance value by wiring and to reduce the noise. If it doesn't meet these conditions, widen the wire width as much as possible, and shorten the wire length.

Note 1) There is no problem even if the Chip on Via method without the pull-out wiring is used.

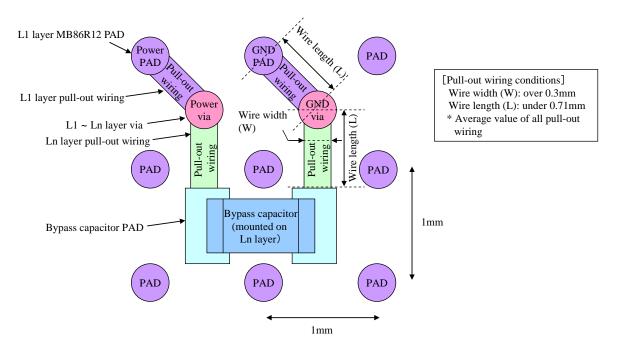


Figure 5-1 Example of mounting a bypass capacitor

